

PATENT  
UNITED STATES PATENT AND TRADEMARK OFFICE

JCS86 U.S. PRO  
09/716708  
11/20/00

APPLICANT: SIEBERT ET AL 2

TITLE: EPITAXIALLY COATED SEMICONDUCTOR WAFER AND PROCESS FOR  
PRODUCING IT

SUBMISSION OF INFORMATION DISCLOSURE STATEMENT  
OF DR. WOLFGANG STAUDACHER

ATT: BOX PATENT APPLICATION  
Assistant Commissioner for Patents  
Washington, D.C. 20231

#4  
52401  
Payton

Dear Sir:

Applicants wish to bring to the attention of the Patent Examiner the attached Information Disclosure Statement, duly signed by Dr. Wolfgang Staudacher and the seven (7) references listed on the enclosed Form PTO-1449 and attached thereto.

The relevance of these references is that they are cited in the present patent application and may be material to the examination of the application.

It is respectfully requested that this Information Disclosure Statement be considered and placed into the application file.

Respectfully submitted,

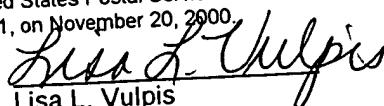
Dr. Wolfgang SIEBERT ET AL 2

  
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Encl: 1) Information Disclosure Statement Of Dr. Wolfgang Staudacher  
2) PTO-form 1449 w/copies of 7 references

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to:  
ASSISTANT COMMISSIONER OF PATENTS, Washington, D.C. 20231, on November 20, 2000.

  
Lisa L. Vulpis

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of  
SIEBERT ET AL  
Serial Number : Group Art Unit:  
Filed:  
For: EPITAXIALLY COATED SEMICONDUCTOR WAFER AND PROCESS FOR  
PRODUCING IT

Information Disclosure Statement

Honorable Commissioner of Patents and Trademarks  
Washington, D.C. 20231

Sir or Madam:

I, Wolfgang Staudacher, associated with the preparation and prosecution of the above-identified application, residing at Seebauerstraße 4, 81735 München, Germany, wish to call the attention of the Patent Examiner to the references enumerated on the enclosed PTO Form-1449.

I believe the documents enumerated on the enclosed Form PTO-1449 and attached thereto, are cited in the enclosed application and may be material to the examination of the application.

Therefore, it is respectfully requested that the foregoing Information Disclosure Statement be considered by the Examiner and incorporated into the file of this application.

I wish to comment as follows concerning the prior art references enumerated on PTO Form-1449:

EP 0 684 634 is already in English language.

EP 0 711 854 is already in English language.

H. M. Liaw and J. W. Rose, Epitaxial Silicon Technology, Academic Press Inc., Orlando, Florida, 1986, p. 71-73 is already in English language.

For DE 198 33 257 an English Derwent Abstract is enclosed.

For DE 199 05 737 an English Derwent Abstract is enclosed.

Signed this 8<sup>th</sup> day of November, 2000

  
Dr. Wolfgang Staudacher